



ALD Technique for Functional Coatings of Nanostructured Materials

Guest Editors:

Dr. Víctor M. de la Prida Pidal

Physics Department, Faculty of
Sciences, University of Oviedo, E-
33007 Oviedo, Spain

Dr. Víctor Vega Martínez

Physics Department, Faculty of
Sciences, University of Oviedo, E-
33007 Oviedo, Spain

Dr. Javier García Fernández

Physics Department, Faculty of
Sciences, University of Oviedo, E-
33007 Oviedo, Spain

Message from the Guest Editors

The conformability and thickness control of thin layers achieved using the atomic layer deposition (ALD) technique have driven the development of new material structures as well as novel devices that are more efficient in many research fields such as magnetism, photonics or biochemistry, among others. The research is still focusing on the development of novel materials and their growth mechanisms, and designing new precursors and deposition approaches.

This Special Issue is focused on, but not confined to, three main research levels involving the ALD technique.

- The development of new precursors and deposition approaches to increase the state of the art of ALD materials.
- Implementation of ALD in combination with other fabrication routes to yield new nanostructured materials.
- Fabrication of advance devices using the ALD technique to improve their performance.

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Editor-in-Chief

Prof. Dr. Shirley Chiang

Department of Physics, University
of California Davis, One Shields
Avenue, Davis, CA 95616-5270,
USA

Message from the Editor-in-Chief

Nanoscience and nanotechnology are exciting fields of research and development, with wide applications to electronic, optical, and magnetic devices, biology, medicine, energy, and defense. At the heart of these fields are the synthesis, characterization, modeling, and applications of new materials with lower nanometer-scale dimensions, which we call “nanomaterials”. These materials can exhibit unusual mesoscopic properties and include nanoparticles, coatings and thin films, metal-organic frameworks, membranes, nano-alloys, quantum dots, self-assemblies, 2D materials such as graphene, and nanotubes. Our journal, *Nanomaterials*, has the goal of publishing the highest quality papers on all aspects of nanomaterial science to an interdisciplinary scientific audience. All of our articles are published with rigorous refereeing and open access.

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Nanomaterials Editorial Office
MDPI, St. Alban-Anlage 66
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